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HEAT-STABLE COPOLYCONDENSATE MOLDING MATERIALS

[75] Gerhard Heinz, Weisenheim, Fed. Inventor:

Rep. of Germany

[73] BASF Aktiengesellschaft, Assignee:

United States Patent

Ludwigshafen, Fed. Rep. of

Germany

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Related U.S. Patent Documents

Reissue of: [64] Patent No.: 4,925,910 Issued: May 15, 1990 Appl. No.: 36,,446 Filed: Apr. 9, 1987 [30] Foreign Application Priority Data Apr. 30, 1986 [DE] Fed. Rep. of Germany 3614753 [51] Int. Cl.⁵ C08K 3/34 U.S. Cl. 528/171; 528/173; [52] 528/174

[56] References Cited

U.S. PATENT DOCUMENTS

Field of Search 528/171, 173, 174

Primary Examiner—John Kight, III Assistant Examiner-P. Hampton-Hightower Attorney, Agent, or Firm-Oblon, Spivak, McClelland, Maier & Neustadt

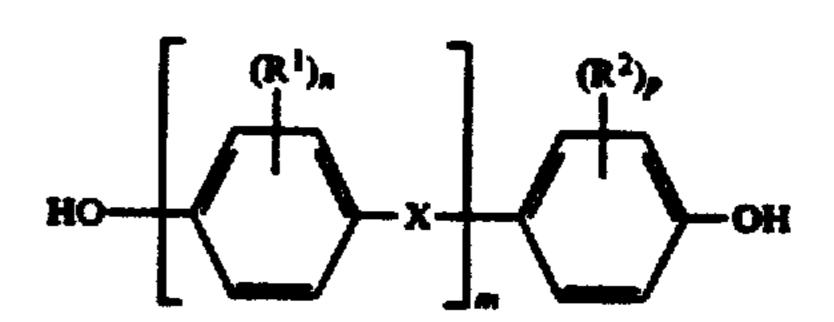
[57] ABSTRACT

Copolycondensate molding materials are obtainable by polycondensation of

from 2 to 98 mol % of 2,2-di-(4'-hydroxyphenyl)-propane (A),

from 2 to 98 mole % of 4,4'-dihydroxydiphenyl sulfone (B) and

from 0 to 96 mole % of (C)



where R1 and R2 are each H, C1-C6-alkyl or C1-C6alkoxy, X is a chemical bond, -S-, -O-, -CO-, CR3R4 (where R3 and R4 are different when n and p are each 0), or SO₂—only when n or p is not 0), R³ and R⁴ are each H, C₁-C₆-alkyl, C₁-C₆-alkoxy, aryl or halogen-substituted alkyl of 1 to 4 carbon atoms, m is 0 or 1, and n and p are each 0, 1, 2, 3, or 4,

with from 1 to 100 mole % of (D)

where R5 and R6 have the same meaning as R1 and R2, and v and w are each 0, 1, 2, 3 or 4, and from 0 to 99 mol % of (E)

$$Y - (R^7) - Z_1 + (R^8) - Z_2 + (R^9) - (R^{10})$$

where R7-R10 are each Cl or F or have the same meanings as R¹ and R², q is 0 or 1, r, s, t and n are each 0, 1, 2, 3 or 4, Z_1 is $-SO_2$ — or -CO— and Z_2 is -O—, -S-, -SO₂-, -CO- or a chemical bond,

with the proviso that one or more of the components C and E are present and the molar ratio of B to the sum of A and C is not greater than 1.

7 Claims, No Drawings

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HEAT-STABLE COPOLYCONDENSATE MOLDING MATERIALS

Matter enclosed in heavy brackets [] appears in the original patent but forms no part of this reissue specification; matter printed in italics indicates the additions made by reissue.

SUMMARY OF THE INVENTION

The present invention relates to heat-stable copolycondensate molding materials which contain polyarylene sulfone and polyarylene ether sulfone units in random distribution and are obtainable by polycondensation of a mixture of

(A) from 2 to 98 mole %, based on the sum of (A)-(C), of

(B) from 2 to 98 mole %, based on the sum of (A)-(C), of

$$HO SO_2 OH$$

and

(C) from 0 to 96 mol %, based on the sum of (A)-(C), of

$$HO$$
 $(\mathbb{R}^1)_n$
 $(\mathbb{R}^2)_p$
 OH

where X is a chemical bond or

$$-s-$$
, $-o-$, $-c-$,

(only when n or p is not 0), R¹ and R² are each alkyl or alkoxy, each of 1 to 6 carbon atoms, R³ and R⁴ are each hydrogen, alkyl of 1 to 6 carbon atoms, aryl or halogensubstituted alkyl of 1 to 4 carbon atoms, m is 0 or 1 and n and p are 0, 1, 2, 3 or 4. with

(D) from 1 to 100 mol %, based on the sum of (D) and (E), of

where R⁵ and R⁶ are each hydrogen or have the same 10 meanings as R¹ and R², and v and w are each 0, 1, 2, 3 or 4, and

(E) from 0 to 99 mole %, based on the sum of (D) and (E), of

$$Y - (R^7)_r - Z_1 + (R^8)_s - Z_2 + (R^9)_t - (R^{10})_n$$

where Y is Cl or F,
$$Z_1$$
 is $-S$ — or $-C$ —, Z_2

or a chemical bond, R⁷, R⁸, R⁹ and R¹⁰ are each hydrogen, Cl or F or may have the same meanings as R¹ and R², q and p are each 0 or 1 and r, s, t and u may each be an integer from 0 to 4, with the proviso that one or more of the components, C and E are present and the molar ratio of B to the sum of A+C is not greater than 1.

The present invention furthermore relates to a process for the preparation of such copolycondensate molding materials and their use for the production of printed circuit boards and electrical plug connections, and to molding which are obtained from the novel copolycondensate molding materials as essential components.

DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

Polyethersulfones containing the general structural unit

(frequently referred to, as below, simply as polysulfones) are characterized by very low water absorption and hence very good dimensional stability (of the moldings produced from them). However, the heat distortion resistance (which is frequently described in terms of the maximum temperature during continuous operation) is not sufficient for some applications, particularly in the case of printed circuit boards (also referred to as PCB's) produced from these materials.

Compared with polysulfones, polyethersulfones containing the general structural unit

possess better heat distortion resistance, but the water absorption is substantially higher. The consequence of this is that moldings produced from polyethersulfones tend to swell and become distorted, which is undesirable when used in the electrical industry and electronics (production of printed circuit boards).

Mixtures of polysulfones and polyethersulfones exhibit a linear relationship between mixing ratio and water absorption, but the polysulfone component has an adverse effect on the heat distortion resistance. Moreover because of the incompatibility of the two components, moldings produced from such mixtures are not transparent, and this is a substantial disadvantage. U.S. Pat. No. 4,175,175, EP-A 113 112 and EP-A 135 130 describe copolycondensates which are obtainable by condensation of mixtures of 2,2-di-(4-hydroxyphenyl)-propane (bisphenol A) and 4,4'-dihydroxyphenyl sulfone (bisphenol S) with 4,4'-dichlorodiphenyl sulfone (DCDCPS).

EP-A 113 112 also describes copolycondensates of a mixture of dihydroxy compounds, A, B and C and dihalogen compounds D. However, the molar ratio of B to A and C is always greater than 1, which has an adverse effect on the water absorption.

Although these copolycondensates have in general better properties than the polysulfones or polyethersulfones, the heat distortion resistance and the stress cracking resistance are still unsatisfactory. These copolycondensates can be used only to a very restricted extent for the production of printed circuit boards.

It is an object of the present invention to provide heat-stable polycondensates which have a balanced property spectrum, ie. sufficient heat distortion resistance coupled with low water absorption and high stress cracking resistance, and are suitable for the production of circuit boards, in particular printed circuit boards.

We have found that this object is achieved, according to the invention, by the heat-stable copolycondensate molding materials defined at the outset.

Preferred copolycondensates of this type are mentioned in the subclaims and in the detailed description below.

The novel heat-stable copolycondensates are obtainable by polycondensation of a mixture of aromatic dihy-

droxy compounds A, B and, if required, C with aromatic dihalogen compounds D and, if required, E, and it is essential for one or more of the compounds C and E to be present.

The dihydroxy compound A is 2,2-di-(4-hydroxyphenyl) -propane, which is known as bisphenol A, and the dihydroxy compound B is 4,4'-dihydroxyphenyl sulfone, which is also referred to as bisphenol S.

The dihydroxy compounds C are of the general for-10 mula

HO
$$\longrightarrow$$
 $X \longrightarrow$ OH

$$-s-, -o-, -c-, -c-$$

(when n or p is not 0), R¹ and R² are each alkyl or alkoxy, each of 1 to 6 carbon atoms, R³ and R⁴ are each hydrogen, alkyl or alkoxy of 1 to 6 carbon atoms, aryl or halogen-substituted alkyl of 1 to 4 carbon atoms, m is 0 or 1, preferably 1, and n and p are each 0, 1, 2, 3, or 4.

R¹ and R² are each preferably alkyl of 1 to 4 carbon atoms, eg. methyl, ethyl, isopropyl, n-propyl or n-, isoor tert-butyl or corresponding alkoxy groups. Methyl and ethyl are particularly preferred.

Preferred substituents R³ and R⁴ are C₁-C₄-alkyl groups, as described for R¹ and R², aryl or halogen-substituted alkyl, such as CF₃ and CCl₃, to mention but two examples.

m is 0 or 1, and is preferably 1 particularly when p is 0, ie. no substituents R² are present.

n and p may each be 0, 1, 2, 3, or 4, preferably 0, 1, 2 or 3.

A few examples of preferred dihydroxy compounds are listed below.

Di-(4-hydroxyphenyl)-methane

2,2-Di-(4-hydroxyphenyl)-ethane

1-Phenyl-1,1-di-(4-hydroxyphenyl)-methane

Diphenyl-di-(4-hydroxyphenyl)-methane

Tetramethylbisphenol A

4,4'-Dihydroxydiphenyl ether

4,4'-Dihydroxydiphenyl sulfide

Dihydroxybenzophenone

1,4-Di-(4'-hydroxyphenylcarbonyl)-benzene

Tetramethylbisphenol S

Hydroquinone

2,3,6-Trimethylhydroquinone

-continued

The mixture of the dihydroxy compounds A, B and, where relevant, C contains from 2 to 98 mole % of A, from 2 to 98 mol % of B and from 0 to 96 mol % of C, the percentages in each case being based on the sum of A-C.

Preferred mixtures are those which contain from 20 to 80, in particular from 25 to 70, mol % of A, from 20 to 80, in particular from 25 to 70, mol % of B and from 0 to 60, in particular from 5 to 60, mol % of C.

Component C is present in the mixture whenever 30 component E is not used. In this case, as a rule from 5 to 60, preferably from 10 to 40, mol %, based on the sum of compounds A to C, of dihydroxy compound C are used.

The molar ratio of dihydroxy compound B to the sum of A and C is not more than 1. If this ratio is greater than 1, the water absorption is adversely affected and becomes too high. Products of this type are less suitable for the production of components in the electrical industry and electronics.

Compounds D and E, which are reacted with the mixture of compounds, A, B and, if required, C to give the novel heat-stable copolycondensate molding materials, are aromatic dihalogen compounds. Compound D is 4,4'-dichloro- or 4,4'-difluorodiphenyl sulfone or their 45 C₁-C₆-alkyl-substituted or halogen-substituted derivatives, such as 3,3,5,5'-tetramethyl-4,4'-dichlorodiphenyl sulfone or the corresponding fluorine compound. The

two halogen substituents may be identical or different. v and w can be 0, 1, 2, 3 or 4, and are preferably 0, 1 or 2. The compounds E are of the general formula

$$Y - \sum_{(R^7)_r} Z_1 + \sum_{(R^8)_s} Z_2 + \sum_{(R^9)_r} Z_1)_p - \sum_{(R^{10})_n} Y$$
where Y is Cl or F, Z_1 is $-S - \text{ or } -C - , Z_2$

$$is - O - , -S - , -S - , -C - \bigcup_{(R^9)_r} O$$

or a chemical bond, R⁷, R⁸, R⁹ and R¹⁰ are each hydrogen, Cl or F or may have the same meanings as R¹ and R², q and p are each 0 or 1 and r, s, t and u may each be an integer from 0 to 4.

Z₂ is preferably a chemical bond, or —SO₂—, and R⁷, R⁸, R⁹ and R¹⁰ are each preferably hydrogen, methyl, ethyl or Cl or F, r, s, t and u may each be 0, 1, 2, 3 or 4, preferably 0, 1 or 2.

Some preferred dihalogen compounds D and E are listed below merely as typical examples.

Name of chlorine compound 4,4'-Dichlorobenzophenone C1.F C1.F

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-continu	
	Name of chlorine compound
C1.F————————————————————————————————————	4,4'-Dichlorodiphenyl sulfone
CH ₃	3,3',5,5'-Tetramethyl-4,4'-dichlorodiphenyl sulfone
Cl.F—Cl.F	3-Chloro-4,4'-dichlorodiphenyl sulfone
Cl.F————————————————————————————————————	3,3'-4,4'-Tetrachlorodiphenyl sulfone
Cl.F— O II O CH ₃	1,3-Dimethyl-4,6-di-(4-chlorophenylsulfonyl)benzene

The amount of dihalogen compound D is from 1 to 100, preferably from 20 to 100, particularly preferably 35 from 50 to 100, mol %, based on the sum of D and E.

The dihalogen compounds E are present when no dihydroxy compound C is used. In this case, the amount of the dihalogen compound E is preferably from 5 to 50, particularly preferably from 10 to 40, mol %, based on 40 the sum of D and E.

The novel copolycondensate molding materials can be mixed with other thermoplastics, for example polyesters, nylons, polyurethanes, polyolefins, polyvinyl chloride and polyoxymethylenes, in amounts of from 5 to 45 50, preferably from 20 to 50, % by weight, based on the molding materials.

They may furthermore be modified with reinforcing fillers and, if required, transparent pigments and other assitants and additives.

Examples of reinforcing fillers are asbestos, carbon and preferably glass fibers, the latter being used in the form of, for example, glass fabrics, mats, surface mats and/or preferably glass rovings or cut glass filaments of low-alkali E glasses having a diameter of from 5 to 200 55 μm, preferably from 8 to 15 μm, which, after being incorporated, have a mean length of from 0.05 to 1 mm, preferably from 0.1 to 0.5 mm. The molding materials reinforced with glass rovings or cut glass filaments contain from 10 to 60, preferably from 20 to 50, % by 60 weight, based on the total weight, of the reinforcing material, while the impregnated-glass fabrics, mats andor surface mats contain from 10 to 80, preferably from 30 to 60, % by weight, based on the total weight, of copolycondensates. Examples of suitable pigments are 65 titanium dioxide, cadmium sulfide, zinc sulfide, barium sulfate and carbon black. Examples of other suitable additives and assistants are dyes, lubricants, eg. graphite

or molybdenum disulfide, abrasives, eg. carborundum, light stabilizers and stabilizers against hydrolysis. The pigments, additives and assistants are usually used in amounts of from 0.01 to 3% by weight, based on the weight of polycondensates.

Wollastonite, calcium carbonate, glass spheres, quartz powder, silicon nitride and boron nitride or mixtures of these fillers may also be used.

A, B and, where relevant, C with the dihalogen compounds D and, where relevant, E can be carried out in principle by the processes which are known for the preparation of polysulfones or polyethersulfones and are described in the literature. A preferred process for the preparation of the novel copolycondensates is described below as a typical example.

The mixture of the aromatic dihydroxy compounds A, B and, if required, C can be reacted with aromatic dihalogen compounds in a molar ratio of from 0.8:1 to 1.2:1, preferably from 0.9:1 to 1.1:1, in particular from 0.98:1 to 1.02:1, and particularly preferably with an equimolar amount of aromatic dihalogen compounds in the presence of from 1.0 to 2.0, preferably from 1.05 to 1.5, moles of an anhydrous alkali metal carbonate, in particular K_2CO_3 , in an aprotic, polar solvent.

Preferred aprotic polar solvents are N-substituted acid amides and lactams, N,N-dimethylformamide, N,N-dimethylacetamide and N-methylpyrrolidone may be mentioned merely by way of example.

If desired, an azeotrope former may be added to the solvent in order to remove the water of reaction. Compounds of this type are described in the literature. How-

ever, an azeotrope former may also advantageously be omitted.

The amount of monomers is in general from 20 to 80, preferably from 30 to 70, in particular from 40 to 60% by weight, based on the total amount of the solvent.

The major part of the water of reaction formed can be removed at from 100° to 200° C., preferably from 130° to 180° C. This can be effected, for example, by heating alone, by adding an azeotrope former or, preferably, by reducing the pressure.

The condensation can then be continued at from 180° to 220° C. until the desired molecular weight or the desired degree of condensation is reached.

The total reaction time is, as a rule, from 5 to 20, preferably from 7 to 15, hours and is of course depen- 15 dent on the reaction conditions (temperature and pressure) and on the desired molecular weight of the product.

After the polycondensation, the product can be reacted with an arylating or alkylating agent, eg. methyl 20 chloride, in order to stabilize free terminal phenolate groups. This reaction is preferably carried out at from 50° to 200° C., preferably from 50° to 150° C.

The suspended alkali metal halide obtained in the polycondensation can be separated off by means of a 25 suitable separating apparatus, for example a clarifying filter or a centrifuge.

The copolycondensate can be isolated from the solution by evaporation of the solvent or precipitation in a suitable nonsolvent.

The novel copolycondensation, particularly products prepared by the process described above, generally have a reduced viscosity of from 0.35 to 2.0, preferably from 0.45 to 1.0, in particular from 0.45 to 0.85, measured as a 1% by weight solution in 1:1 phenol/o-35 dichlorobenzene at 25° C.

The novel copolycondensate molding materials are distinguished by their balanced properties. They possess high heat distortion resistance and good stress cracking resistance coupled with low water absorption and very 40 good processability.

The molding materials according to the invention can be used for the production of moldings, film and fibers. Because of their good properties, they are particularly useful for the production of circuit boards and electrical 45 plug connections.

EXAMPLE 1 V (Comparison)

86 kg of N-methylpyrrolidone, 11.41 kg (50 moles) of bisphenol A, 12.51 kg (50 moles) of 4,4'-dihydrox-50 ydiphenyl sulfone and 28.72 kg of 4,4'-dichlorodiphenyl sulfone were dissolved under a nitrogen atmosphere in a 300 l vessel provided with a stirrer and a N₂ connec-

tion, and 15.2 kg (150 moles) of anhydrous potassium carbonate were added.

The reaction mixture was first heated for one hour at 180° C. under 300 mbar (30 kPa) with constant removal of the water of reaction and N-methylpyrrolidone by distillation, and was kept at this temperature for 3 hours. The reaction was then continued for 6 hours at 190° C.

The polycondensation was terminated by adding methyl chloride at 150° C. and carrying out the reaction for 2 hours under pressure (0.5 bar).

After the addition of 125 kg of N-methylpyrrolidone, the inorganic components were filtered off and the polymer was isolated as a solid by precipitation in methanol. After drying at 100° C. under reduced pressure, the polymer was converted to granules.

EXAMPLE 2 V (Comparison)

The procedure described in Example 1 was followed, except that 25 mol % of bisphenol A and 75 mole % of 4,4'-dihydroxydiphenyl sulfone were used.

EXAMPLE 3 V (Comparison)

The procedure described in Example 1 was followed, except that a mixture of 75 mol % of bisphenol A and 25 mol % of 4,4'-dihydroxydiphenyl sulfone (DHDPS) was used.

EXAMPLE 4 V (Comparison)

A 50:50 (mol %) mixture of a polysulfone and a po-30 lyethersulfone was used.

EXAMPLE 5 to 13

The procedure described in Example 1 was followed, except that the dihydroxy compounds and dihalogen compounds stated in the Table were used.

The following abbreviations are used in the Table:

TABLE

Bis A	Bisphenol A
T-Bis A	Tetramethylbisphenol A
DHDPS	4,4'-dihydroxyphenyl sulfone
DHDP	4,4'-dihydroxydiphenyl
T-DHDP	3,3',5,5'-tetramethyl-4,4'-dihydroxydi- phenyl
TMH	2,3-trimethylhydroquinone
DCDPS	4,4'-dichlorodiphenyl sulfone
DDP	1,10-di-(4'-chlorophenylsulfonyl)-diphenyl
DDB	1,3-dimethyl-4,6-di-(4'-chlorophenyl- sulfonyl)-benzene.

Table 1 also shows the heat distortion resistance (Tg) and the water absorption after storage under standard conditions of temperature and humidity (23° C., 50% relative humidity) and after storage in H₂O at 23° C., for 180 days in each case.

TABLE

Example	Component A (mol)	Component B (mol)	Component C (mol)	Component D (mol)	Component E (mol)		Water absorption	
						Tg *C.	Standard conditions	H ₂ O
1V+	Bis A (0.05)	DHDPS (0.05)		DCDPS (0.1)		210	0.14	1.05
2V+	Bis A (0.025)	DHDPS (0.075)		DCDPS (0.1)		215	0.21	1.37
3 V +	Bis A (0.075)	DHDPS (0.025)		DCDPS (0.1)		197	0.11	0.78
4V*+			_	—		189/224	0.18	1.15
5	Bis A (0.025)	DHDPS (0.05)	T-Bis A (0.025)	DCDPS (0.1)		252	0.12	0.89
6	Bis A (0.025)	DHDPS (0.05)	DHDP (0.025)	DCDPS (0.1)	-	225	0.12	0.92
7	Bis A	DHDPS	T-DHDP	DCDPS	_	241	0.10	0.88

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TABLE-continued

Example	Component A (mol)	Component B (mol)	Component C (mol)	Component D (mol)	Component E (mol)	Tg °C.	Water absorption	
							Standard conditions	H ₂ O
	(0.025)	(0.05)	(0.025)	(0.025)				
В	Bis A	DHDPS		DCDPS	DDP	225	0.16	1.09
	(0.05)	(0.05)		(0.05)	(0.05)			
9	Bis A	DHDPS		DCDPS	DDP	245	0.17	1.11
	(0.05)	(0.05)		(0.075)	(0.025)			
10	Bis A	DHDPS		DCDPS	DDB	225	0.13	0.99
	(0.05)	(0.05)		(0.05)	(0.05)			
11	Bis A	DHDPS	TMH	DCDPS		215	0.15	1.10
	(0.0375)	(0.05)	(0.0125)	(0.1)				
12	Bis A	DHDPS	DHDP	DCDPS		221	0.13	1.03
	(0.025)	(0.075)	(0.05)	(0.1)				
13	Bis A	DHDPS	T-DHDP	DCDPS		226	0.10	0.90
	(0.055)	(0.02)	(0.025)	(0.1)				

*50:50 mixture of polysulfone and polyethersulfone

+Examples 1 to 4 are Comparative Examples

We claim:

1. A heat-stable copolycondensate molding material which contains polyarylene sulfone and polyarylene ether sulfone units in random distribution and is obtainable by polycondensation of a mixture of

(A) from 2 to 98 mol %, based on the sum of (A)-(C), of

$$HO$$
 CH_3
 CH_3
 CH_3
 CH_3

(B) from 2 to 98 mol %, based on the sum of (A)-(C),

and

(C) from 0 to 96 mol %, based on the sum of (A)-(C), of

$$HO$$
 $(R^1)_n$
 $(R^2)_p$
 OH

where X is a chemical bond or

$$-s-$$
, $-o-$, $-c-$,

(only when n or p is not 0), R¹ and R² are each alkyl or alkoxy, each of 1 to 6 carbon atoms, R³ and R⁴ are each hydrogen, alkyl of 1 to 6 carbons atoms, aryl or halo-

gen-substituted alkyl of 1 to 4 carbon atoms, m is 0 or 1 and n and p are 0, 1, 2, 3 or 4, with

(D) from 1 to 100 mol %, based on the sum of (D) and (E), of

Y-
$$SO_2$$
- $(\mathbb{R}^6)_{W}$ -OH

where R^5 and R^6 are each hydrogen or have the same meanings as R^1 and R^2 , Y is Cl or F, and v and w are each 0, 1, 2, 3 or 4, and

(E) from 0 to 99 mol %, based on the sum of (D) and (E), of

$$Y - \left(\begin{array}{c} \\ + \\ (R^7)_r \end{array}\right) - \left(\begin{array}{c} \\ + \\ (R^8)_s \end{array}\right) - \left(\begin{array}{c} \\ + \\ (R^9)_i \end{array}\right) - \left(\begin{array}{c} \\ + \\ (R^{10})_n \end{array}\right) - \left(\begin{array}{c} \\ + \\ (R^{10})_n \end{array}\right)$$

where Y is Cl or F,
$$Z_1$$
 is $-S - \text{or } -C -$, Z_2

or a chemical bond, R⁷, R⁸, R⁹ and R¹⁰ are each hydrogen, Cl or F or may have the same meanings as R¹ and R², q and p are each 0 or 1 and r, s, t and u may each be an integer from 0 to 4, with the proviso that one or more of the components C and E are present and the molar ratio of B to the sum of A+C is not greater than 1.

2. A heat-stable copolycondensate molding material as claimed in claim 1, which is obtainable by polycondensation of a mixture of

from 25 to 70 mol % of A, from 25 to 70 mol % of B and

from 5 to 60 mol % of C,

the percentages in each case being based on the sum of A to C, with

from 1 to 100 mol % of D and from 0 to 99 mol % of E,

the percentages in each case being based on the sum of D and E.

3. A heat-stable copolycondensation molding material as claimed in claim 1, which is obtainable by polycondensation of a mixture of

from 20 to 80 mol % of A

from 20 to 80 mol % of B and

from 0 to 60 mol % of C,

the percentages in each case being based on the sum of A to C, with

from 50 to 95 mol % of D and

from 5 to 50 mol % of E,

the percentages in each case being based on the sum of D and E.

4. A heat-stable copolycondensate molding material as claimed in claim 1, which is obtainable by polycondensation of a mixture of

from 25 to 70 mol % of A from 25 to 70 mol % of B and

from 5 to 60 mol % of C, the percentages in each case being based on the sum of A to C, with

from 50 to 95 mol % of D and

5 from 5 to 50 mol % of E,

the percentages in each case being based on the sum of D and E.

- 5. A molding which is obtainable from a heat-stable copolycondensate molding material as claimed in claim 10 1 as the central component.
 - 6. A printed circuit board consisting of a heat-stable copolycondensate molding material as claimed in claim
- 7. An electrical plug connection consisting of a heat-15 stable copolycondensate molding material as claimed in claim 1.

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